

AZ 4533 – run sheet

Merck (AZ Electronic Materials)

nanyte.com/photoresists/az-4533 · last updated 2026-07-26

Thickness: 2.7–4.7 μm

Softbake: 100 °C · 50 s · hotplate

Develop: Developer AZ 340 (AZ 400K also usable) · Dilution AZ 340 diluted 1:5 with water; no dilution stated for AZ 400K.

Hardbake: 115 °C · 50 s